

Topic :- SEMICONDUCTOR ELECTRONICS: MATERIALS, DEVICES AND SIMPLE CIRCUITS

2 (a)

We know that

$$\beta = \frac{\Delta I_c}{\Delta I_b} \text{ or } \Delta I_c \Delta \beta \Delta I_b = 40 \times 100 \mu\text{A}$$

3 (a)

Number of atoms per unit cells is given by

$$N = N_b + \frac{N_f}{2} + \frac{N_C}{8}$$

where, N_b is the number of atoms centered in the body of the cell, N_f is the number of atoms centered in the face of the unit cell and N_C is the number of atoms centered at the corner.

For fcc lattice $N_b = 0$, $N_f = 6$ and $N_C = 8$

$$\therefore 0 + \frac{6}{2} + \frac{8}{8} = 3 + 1 = 4$$

5 (a)

First diode is in reverse biasing it acts as open circuit, hence no current flows

6 (b)

Here $p - n$ junction as forward biased with voltage
 $= 5 - 3 = 2 \text{ V}$.

$$\therefore \text{Current } I = \frac{2}{200} = \frac{1}{100} = 10^{-2} \text{ A}$$

7 (d)

Radiowaves of constant amplitude can be produced by using oscillator with proper feedback.

8 (a)

$$I_p = 0.004 (V_p + 10V_g)^{3/2} \text{ mA}$$

$$\Rightarrow \frac{\Delta I_p}{\Delta V_g} = 0.004 \left[\frac{3}{2} (V_p + 10V_g)^{1/2} \times 10 \right] \times 10^{-3}$$

$$\Rightarrow g_m = 0.004 \times \frac{3}{2} (120 + 10 \times -2)^{1/2} \times 10 \times 10^{-3}$$

$$\Rightarrow g_m = 6 \times 10^{-4} \text{ mho} = 0.6 \text{ m mho}$$

Comparing the given equation of I_p with standard equation $I_p = K(V_p + \mu V_g)^{3/2}$ we get

$$\mu = 10$$

$$\text{Also from } \mu = r_p \times g_m \Rightarrow r_p = \frac{\mu}{g_m} = \frac{10}{0.6 \times 10^{-3}}$$

$$\Rightarrow r_p = 16.67 \times 10^3 \Omega = 16.67 k\Omega$$

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(a)

In $p-n$ junction, the barrier potential offers resistance to free electrons in n -region and holes in p -region.

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(d)

$$V_{g2} = V_{g1} \left(\frac{V_{p2}}{V_{p1}} \right) = -5 \left(\frac{200}{150} \right) = -6.66 \text{ V}$$

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(b)

Resistivity is the intrinsic property, it doesn't depend upon length and shape of the semiconductors

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(b)

$$n_i^2 = n_e n_h$$

$$(1.5 \times 10^{16})^2 = n_e (4.5 \times 10^{22})$$

$$n_e = 0.5 \times 10^{10} = 5 \times 10^9$$

$$n_h = 4.5 \times 10^{22}$$

$$n_h \gg n_e$$

Semiconductor is p -type and $n_e = 5 \times 10^9 m^{-3}$

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(b)

The output of the circuit is,

$$Y = \overline{A + B}$$

$$= \overline{A} \cdot \overline{B}$$

$$= A \cdot B \quad (\because \overline{\overline{A}} = A \text{ and } \overline{\overline{B}} = B)$$

Which is the output of an AND gate.

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(a)

$$\text{For Ge, } E_g = 0.7 \text{ eV} = 0.7 \times 1.6 \times 10^{-19} \text{ J} = 1.12 \times 10^{-19} \text{ J}$$

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(d)

Boron is a trivalent impurity having three valence electrons. When it is introduced to pure silicon, then such type of semiconductors are called p -type or acceptor type semiconductors.

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(c)

In reverse bias applied to a $p-n$ junction diode raises the potential barrier because p -type material connected to the negative terminal and pulled the holes away from the junction similarly n -type material connected to positive terminal and pulled the electrons. Therefore the depletion region wider.

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(b)

$$\text{In half wave rectifier } V_{dc} = \frac{V_0}{\pi} = \frac{10}{\pi}$$

ANSWER-KEY										
Q.	1	2	3	4	5	6	7	8	9	10
A.	B	A	A	A	A	B	D	A	A	D
Q.	11	12	13	14	15	16	17	18	19	20
A.	B	B	B	B	A	D	A	D	C	B

P E